

PATENT NUMBER

U.S. UTILITY Patent Application

Q.I.P.E. 4
SCANNED Q.A. AA

PATENT DATE

APPLICATION NO. 09/987990	CONT/PRIOR F	CLASS 430	SUBCLASS 5	ART UNIT 1756	EXAMINER ROSASCO
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TITLE

Substrate with multilayer film, reflection type mask blank for exposure, reflection type mask for exposure and production method thereof as well as production method of semiconductor device

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL				CROSS REFERENCE(S)													
CLASS				SUBCLASS		CLASS		SUBCLASS (ONE SUBCLASS PER BLOCK)									
INTERNATIONAL CLASSIFICATION																	

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
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<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent No. _____ _____	(Assistant Examiner) _____ (Date) _____			
			ISSUE FEE	
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<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	(Primary Examiner) _____ (Date) _____		ISSUE BATCH NUMBER	
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